
2SK2926(L), 2SK2926(S)

Silicon N Channel MOS FET
High Speed Power Switching

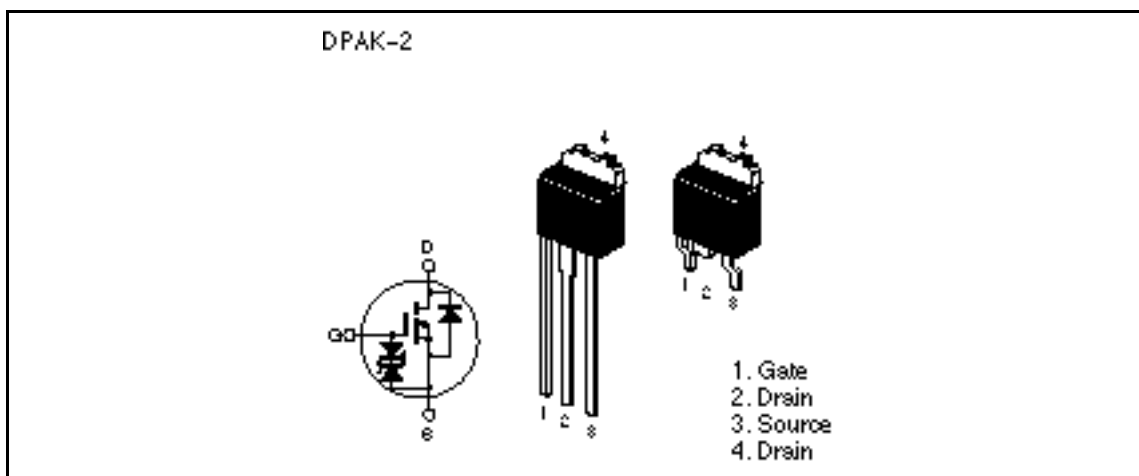
HITACHI

ADE-208-535
1st. Edition

Features

- Low on-resistance
 $R_{DS(on)} = 0.042 \text{ typ.}$
- 4V gate drive devices.
- High speed switching

Outline



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Absolute Maximum Ratings (Ta = 25°C)

Item	Symbol	Ratings	Unit
Drain to source voltage	V_{DSS}	60	V
Gate to source voltage	V_{GSS}	± 20	V
Drain current	I_D	15	A
Drain peak current	$I_{D(pulse)}^{*1}$	60	A
Body to drain diode reverse drain current	I_{DR}	15	A
Avalanche current	I_{AP}^{*3}	15	A
Avalanche energy	E_{AR}^{*3}	19	mJ
Channel dissipation	P_{ch}^{*2}	25	W
Channel temperature	T_{ch}	150	°C
Storage temperature	T_{stg}	-55 to +150	°C

Notes: 1. PW 10μs, duty cycle 1 %

2. Value at Ta = 25°C

3. Value at Ta = 25°C, Rg 50

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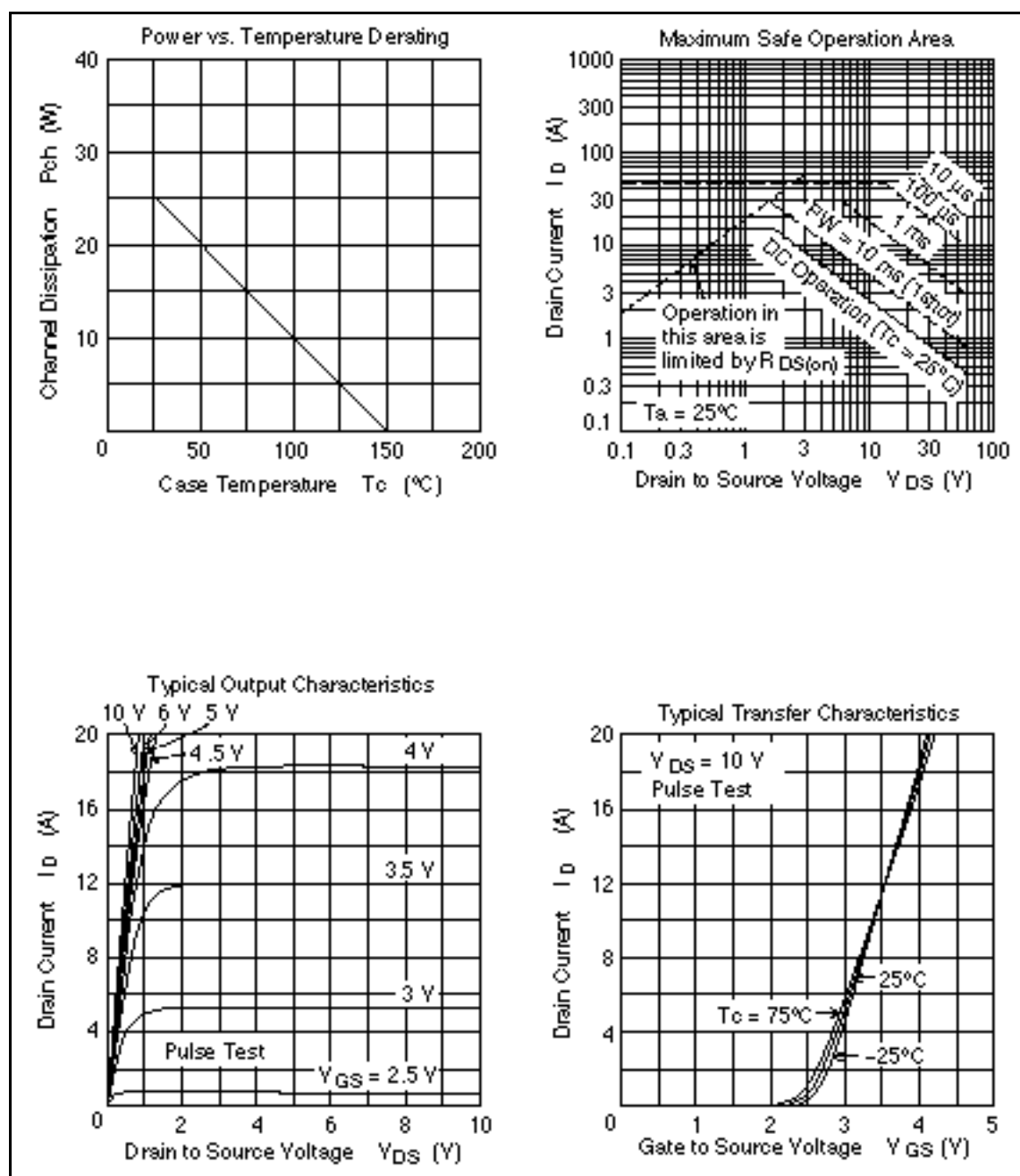
Electrical Characteristics (Ta = 25°C)

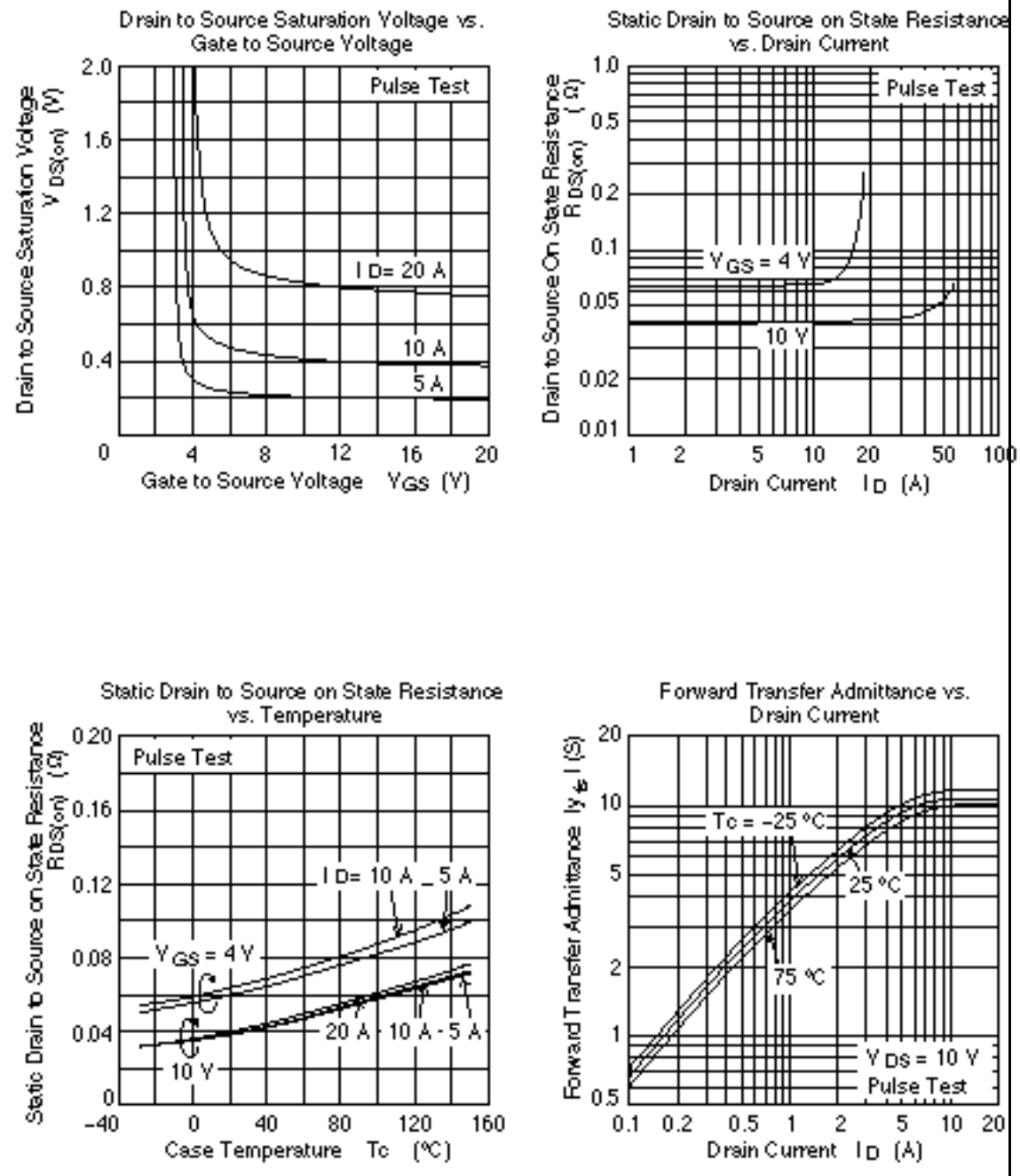
Item	Symbol	Min	Typ	Max	Unit	Test Conditions
Drain to source breakdown voltage	$V_{(BR)DSS}$	60	—	—	V	$I_D = 10\text{mA}$, $V_{GS} = 0$
Gate to source breakdown voltage	$V_{(BR)GSS}$	± 20	—	—	V	$I_G = \pm 100\mu\text{A}$, $V_{DS} = 0$
Zero gate voltage drain current	I_{DSS}	—	—	10	μA	$V_{DS} = 60\text{V}$, $V_{GS} = 0$
Gate to source leak current	I_{GSS}	—	—	± 10	μA	$V_{GS} = \pm 16\text{V}$, $V_{DS} = 0$
Gate to source cutoff voltage	$V_{GS(off)}$	1.5	—	2.5	V	$I_D = 1\text{mA}$, $V_{DS} = 10\text{V}$
Static drain to source on state resistance	$R_{DS(on)}$	—	0.042	0.055		$I_D = 8\text{A}$, $V_{GS} = 10\text{V}^{*1}$
	$R_{DS(on)}$	—	0.065	0.11		$I_D = 8\text{A}$, $V_{GS} = 4\text{V}^{*1}$
Forward transfer admittance	$ y_{fs} $	7	11	—	S	$I_D = 8\text{A}$, $V_{DS} = 10\text{V}^{*1}$
Input capacitance	C_{iss}	—	500	—	pF	$V_{DS} = 10\text{V}$
Output capacitance	C_{oss}	—	260	—	pF	$V_{GS} = 0$
Reverse transfer capacitance	C_{rss}	—	110	—	pF	$f = 1\text{MHz}$
Turn-on delay time	$t_{d(on)}$	—	10	—	ns	$V_{GS} = 10\text{V}$, $I_D = 8\text{A}$
Rise time	t_r	—	80	—	ns	$R_L = 3.75$
Turn-off delay time	$t_{d(off)}$	—	100	—	ns	
Fall time	t_f	—	110	—	ns	
Body to drain diode forward voltage	V_{DF}	—	1.0	—	V	$I_F = 15\text{A}$, $V_{GS} = 0$
Body to drain diode reverse recovery time	t_{rr}	—	55	—	ns	$I_F = 15\text{A}$, $V_{GS} = 0$ $diF/dt = 50\text{A}/\mu\text{s}$

Note: 1. Pulse test

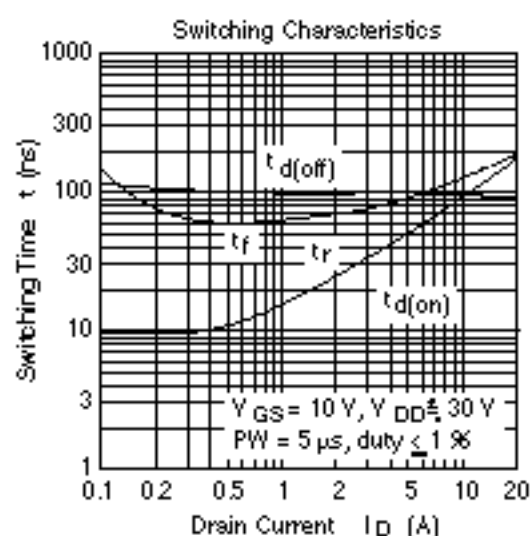
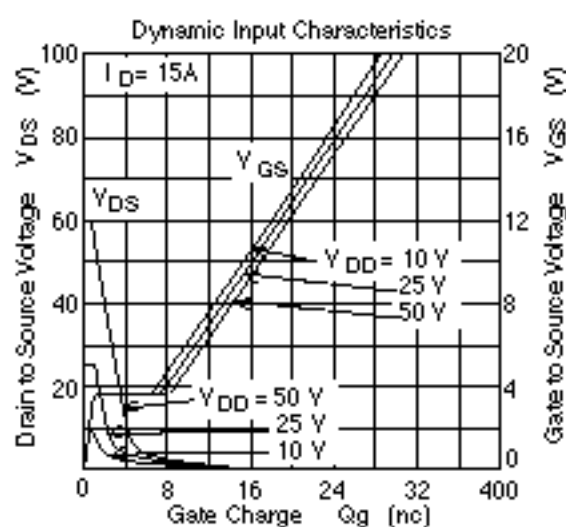
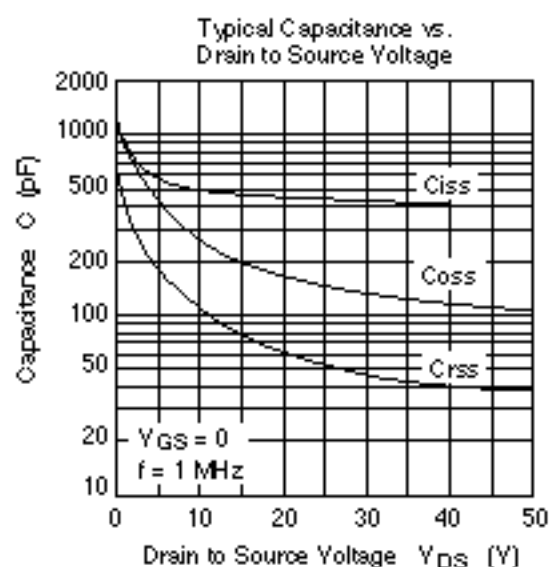
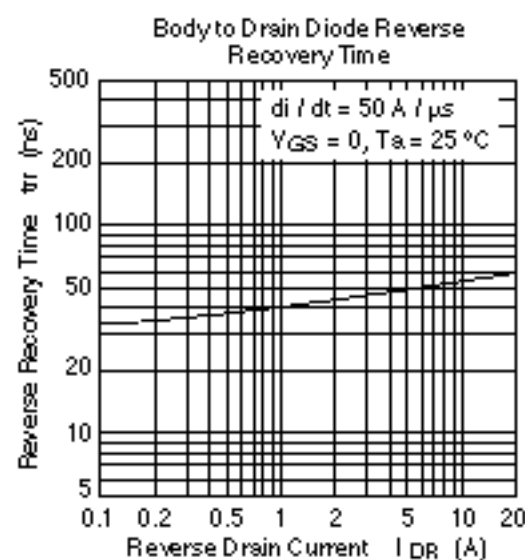
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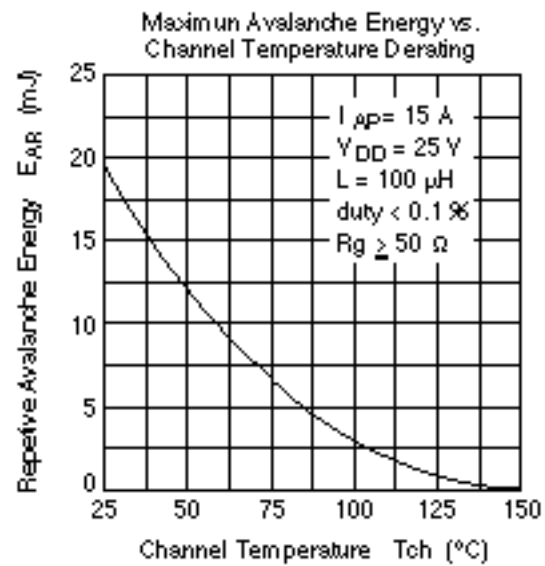
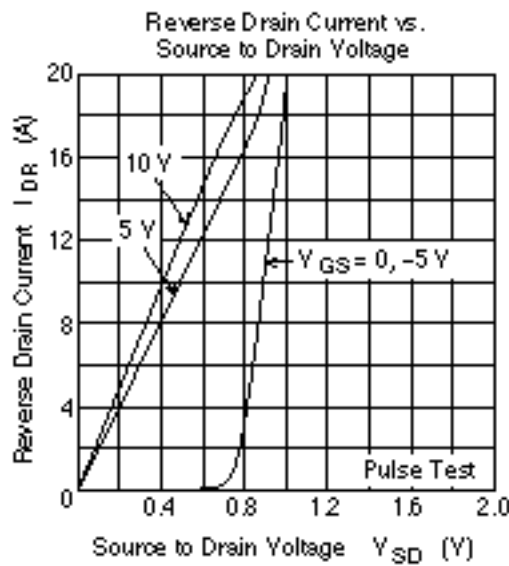
Main Characteristics



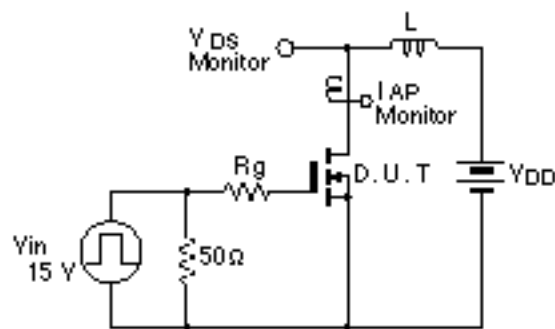


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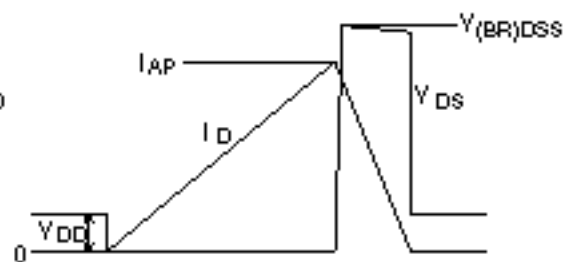


Avalanche Test Circuit

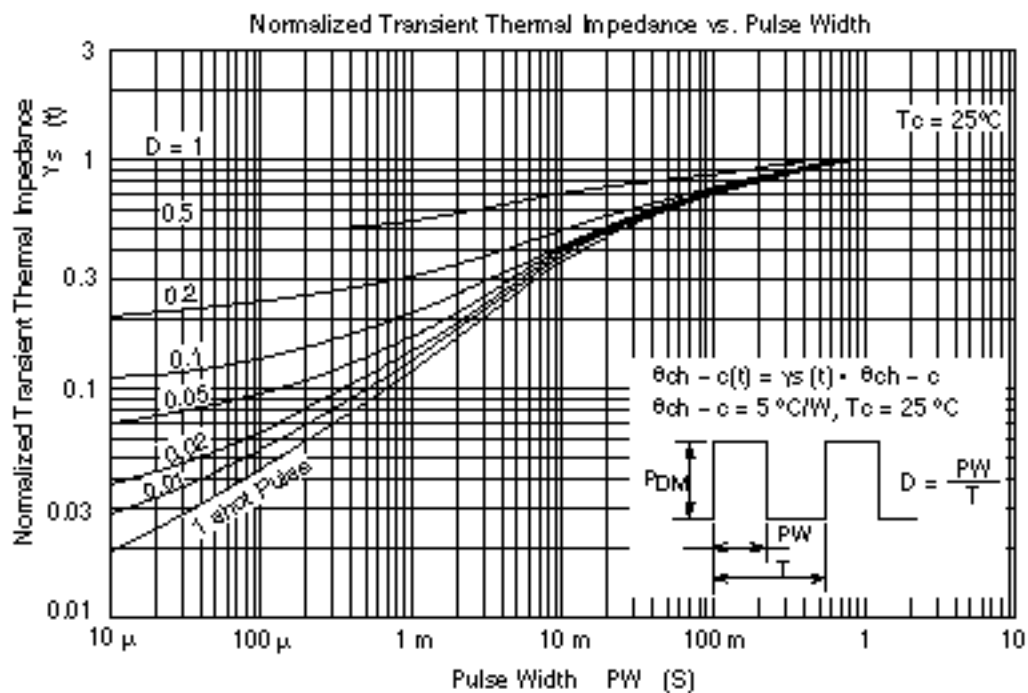


Avalanche Waveform

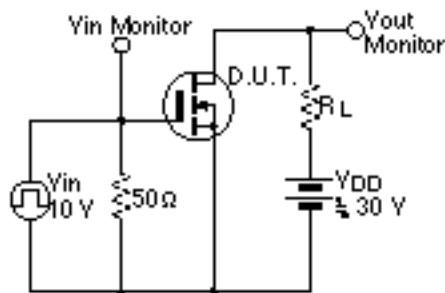
$$E_{AR} = \frac{1}{2} \cdot L \cdot I_{AP}^2 \cdot \frac{V_{DSS}}{V_{DSS} - V_{DD}}$$



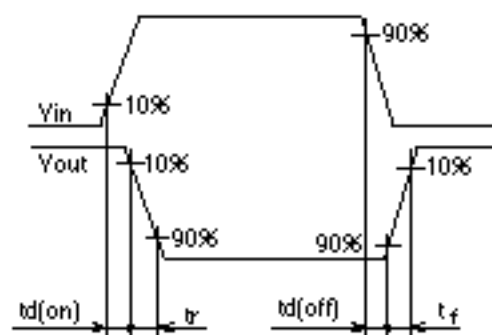
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Switching Time Test Circuit



Switching Time Waveform



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